



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Robert J. Small and Zhefei J. Chen

Title: Compositions for Chemical-Mechanical Planarization of Noble-Metal-Featured Substrates, Associated Methods, and Substrates Produced By Such Methods

Application No.: 10/057,206

Filing Date: January 25, 2002

Examiner: Michael Marcheschi

Group Art Unit: 1755

Docket No.: CHEM.003US0

Conf. No.: 1702

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR CONTINUED EXAMINATION (RCE)

Dear Sir:

This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application.

Please consider the Amendment and Declaration of Robert J. Small and Zhefei J. Chen, which are filed herewith.

The RCE fee required under 37 C.F.R. § 1.17(e) is authorized in an accompanying transmittal letter.

Please contact the undersigned attorney with any questions concerning this request or the above-identified patent application.

**EXPRESS MAIL
LABEL NO.:**

EV 437668108 US

Respectfully submitted,

K. Alison de Runtz
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Reg. No. 37,119

June 16, 2004
Date

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